

EV026158190

Inventor: Yoshiki Hishiro

Title: Semiconductor Constructions; and Methods of Forming
Semiconductor Constructions

Assignee: Micron Technology, Inc.

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10/092874
03/05/02

INFORMATION DISCLOSURE STATEMENT

PURSUANT TO 37 C.F.R. §§ 1.56, 1.97 AND 1.98

In compliance with 37 C.F.R. §§ 1.56, 1.97 and 1.98, the Examiner's attention is directed to the references listed on the attached Form PTO-1449 and copies of which are attached. No admission is made regarding whether all the submitted references are prior art.

Citation of these references is respectfully requested.

Respectfully submitted,

Date:

3/2/02

Attorney:

David G. Latwesen

David G. Latwesen, Ph.D.

Reg. No. 38,533

Wells St. John P.S.

Date:

2/21/02

Inventor:

Yoshiki Hishiro
Yoshiki Hishiro